



## Acknowledgment

Adina Bernice\*

### Editorial

Journal of Nanomaterial and Molecular Nanotechnology is been running successfully released volume 9 and volume 10 containing various articles Research Articles, Review Articles, Short Communication, Commentary, Case Report, etc. In the year 2021 now we received 15 research articles out of which 9 articles got rejected due to various and valid reasons and a total of 12 articles got published. We with immense pleasure say that researchers of around 24 people all around the world gave us their feedback on our paper. Journal of Nanomaterials and Molecular Nanotechnology is honored to have two amazing personalities as review members Dr. Kishore Chand and Prof. Khawla Salah Khashan from the University of Technology in Iraq. Reviewers members added on the board gave their valuable comments and feedback to more than 2 Manuscripts. Along with this we would like extended to special thank you to our most promising Editor Dr. Lihong from Northwestern Polytechnic University, China for helping the Journal maintain its quality and to improve its value. I would also thank all other Authors, Reviewers, and Editors for contributing to the growth of the journal. We thank all those members who helped in achieving the journal's main motive which was to help people to understand the world of Nanosize in a better and subtle way and keeping them connected to research work. To pass the information in such a way the person who isn't an expert in the field will always find it easy and interesting to understand the concept. I would also extend my gratitude to the readers of the journal

of Nanomaterials and Molecular Nanotechnology for showing love and interest in the publication board. It was soul co-dependency and love among the author, reviewer, readers, and editors which made the Journal of Nanomaterial and Molecular Nanotechnology achieve its fantastic success.

I would like to take this chance to invite authors from all over the world to submit their papers in the Journal of Nanomaterial and Molecular Nanotechnology, authors are welcome to submit their research papers, review comments, opinion, perspective, short letter, case studies, mini review, image article, case report, editorial note, etc. We welcome all those papers which cover the field of nanotechnology and molecular nanotechnology including nanoimprints, nanotubes, green nanotechnology, nanorobotics, nanolithography, nanosurgery, nanopolice, nanomedicine etc till now. Authors have been a genuine inspiration and key in setting up JNMN among one of the best journals for publication in the subject of Nanotechnology. I express gratitude towards them all for considering and trusting JNMN as the stage for publishing their significant work. I additionally thank all authors for their caring co-activity stretched out during the different phases of processing of the articles in JNMN for the achievement of any journal, reviewers are a fundamental part and subsequently they merit earnest appreciation. The editors greatly appreciate the contribution of reviewers who have dedicated their valuable time and efforts in reviewing the assigned manuscripts, which is crucial to the journal's editorial decision-making process. We hope to continue to work with all authors, editors, reviewers members in the upcoming future too.

### Author Affiliation

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\*Corresponding author: Adina Bernice, Editorial Office, Journal of Nanomaterial and Molecular Nanotechnology, London, E-mail: [nanomolecules@epujournals.com](mailto:nanomolecules@epujournals.com)

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